

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

**Applicant(s):** Keith J. Machia, et al.

**Examiner:** Unassigned

**Serial No:** Unassigned

**Art Unit:** Unassigned

**Filed:** Herewith

**Docket:** BUR920010164US2 (15016A)

**For:** METHOD OF PHOTOLITHOGRAPHIC  
EXPOSURE DOSE CONTROL AS A  
FUNCTION OF RESIST SENSITIVITY

**Date:** October 23, 2003

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**PRELIMINARY AMENDMENT**

Sir:

In connection with filing the above-identified application under 37 C.F.R. §1.53(b), applicants submit the following amendments and remarks for consideration by the Examiner and entry of record in the above-identified patent application.

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Dated: October 23, 2003

  
Steven Fischman